# **NAVOLCHI** 1<sup>st</sup> Review Meeting

November 27<sup>th</sup> 2012, Brussels



FP7-ICT-2011-7 GA 288869

Work Package 5 Presentation Dries Van Thourhout IMEC, Belgium



Nano Scale Disruptive Silicon-Plasmonic Platform for Chip-to-Chip Interconnection

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# Outline



- **1. WP Position in Project.**
- 2. WP Objectives.
- 3. Milestones and Deliverables.
- 4. Status of Work: Achievements.
- 5. Resources: Budget and Manpower
- 6. Summary and Outlook.





#### Overall Objective :

# Design and implement optical and electrical interfaces for plasmonic interconnect

### Specific Objectives:

- Coupling light between silicon back bone and plasmonic devices
- Beam Shaping grating couplers to direct light between chips
- Compact filters for noise suppression
- Specify and implement Dual Die Communication Module (DDCM)

### **Milestones and Deliverables**



D5.1	DDCM specification document	5	ST	R	CO	6	04/2012
<mark>戊</mark> D5.2	DDCM with electrical PHY design and verification data base	5	ST	R	со	12	10/2012
D5.3	Compact optical filters (2nm bandwidth, >30nm FSR) and first generation beam shapers	5	IMCV	R	со	21	07/2013
D5.4	Generic DDCM compatible with plasmonic-based PHY specification document	5	ST	R	PU	24	10/2013
D5.5	Report on plasmonic waveguide couplers	5	IMCV	R	со	24	10/2013



## **Milestones and Deliverables**



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🔥 MS25	Decision on optimized plasmonic waveguide couplers	5	KIT	6	04/2012
🔥 MS26	Fabrication of plasmonic waveguide couplers with less than 3 dB coupling loss	5	кіт	12	10/2012
MS27	Design of first generation beam shapers and compact optical filters		IMCV	12	10/2012
MS28	DDCM with electrical PHY design and verification	5	ST	12	10/2012
MS29	Data codecs for power consumption reduction	5	ST	15	01/2013
MS30	Decision on plasmonic waveguide couplers with less than 3 dB coupling loss	5	KIT	15	01/2013
MS31	Fabrication of compact optical filters and first generation beam shapers		IMCV	18	04/2013
MS32	Data codecs for error detection and correction	5	ST	18	04/2013
MS33	Design of second generation beam shapers	5	IMCV	24	10/2013
MS34	Generic DDCM compatible with plasmonic-based PHY	5	ST	24	10/2013
MS35	Fabrication of compact optical filters and first generation beam shapers	5	IMCV	30	04/2014
MS36	DDCM evolution for NiP solutions	5	ST	30	04/2014



# Main achievements



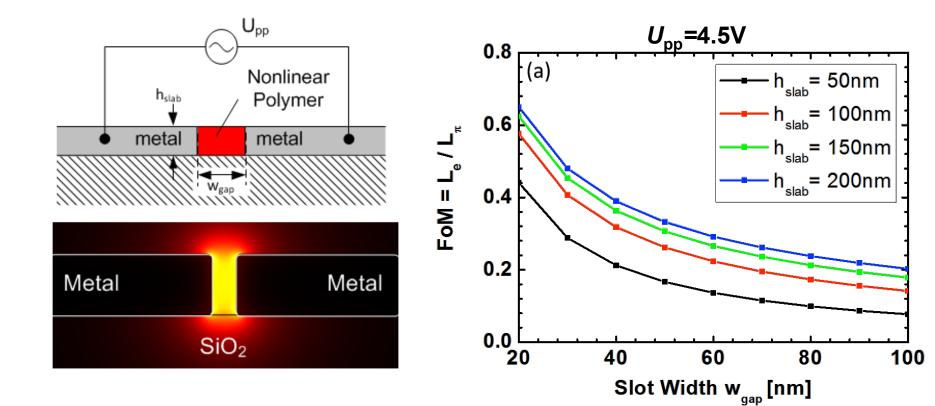
- DDCM functional specification completed (M5.2/D5.1)
- DDCM design activity completed (MS5.5/D5.2)
  - VHDL design completed
    - All features in place (STNoC support, virtual wires, Qos, creditbased flow control, PHY adapter, electrical PHY)
  - Verification environment in place for both VHDL and netlist
  - Full regression in place and passing
- DDCM design characterization completed
  - Area: around 300 Kgates
  - Speed: up to 450 MHz
  - PHY Tx crossing latency: 3.5 cycles at 450MHz
  - PHY Rx crossing latency: 0.5 cycles at 450MHz
  - Total crossing latency: 4 cycles at 450MHz i.e. 8.88ns
- Patent proposal about alternative optical link proposed by ST Support Technologies Group has been submitted and is currently under evaluation by ST patent committee



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# **3D Design of the Phase Modulator**

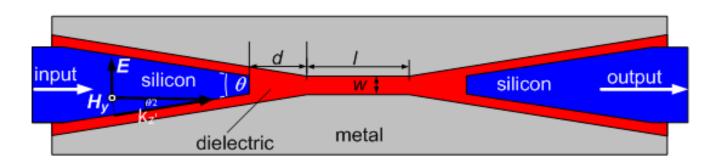


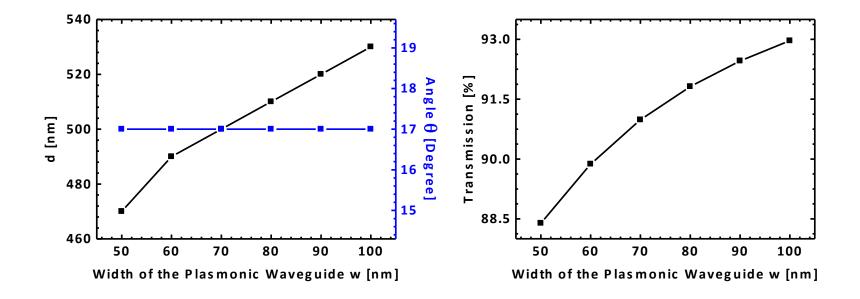


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# **SPP Excitation in the Slot**



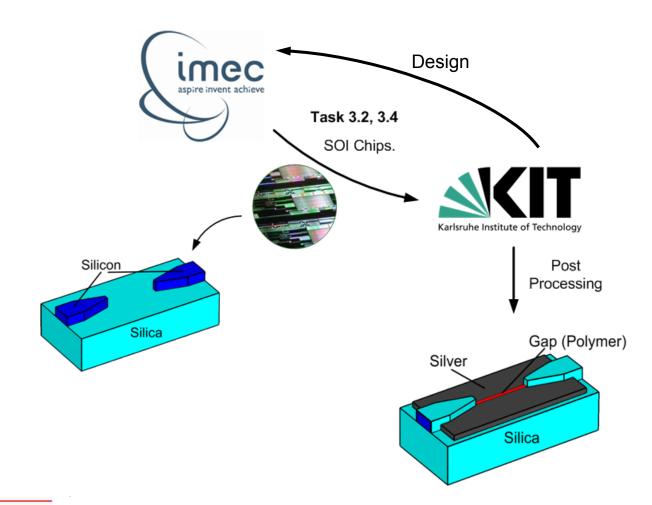




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# **Fabrication by KIT & IMEC**

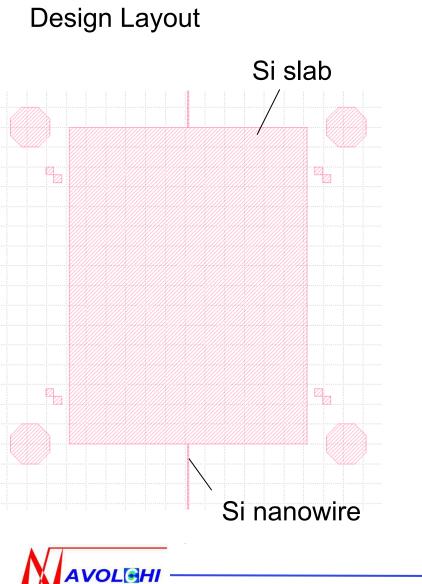




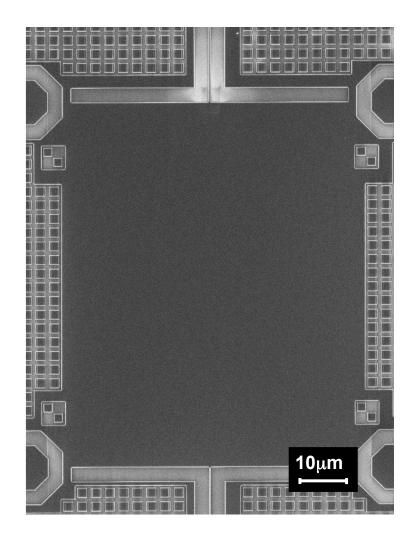
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# **Fabrication by KIT & IMEC**





#### SOI chip Fabricated by IMEC

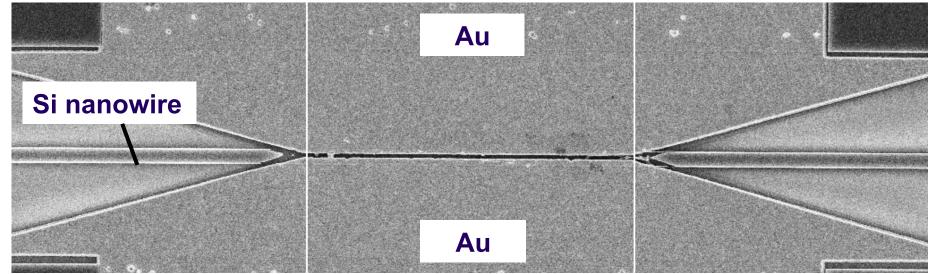


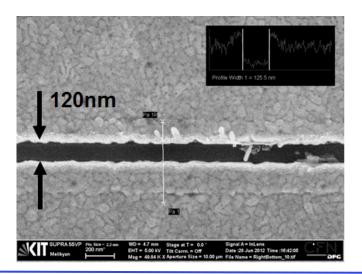
Nano Scale Disruptive Silicon-Plasmonic Platform for Chip-to-Chip Interconnection

# **Fabrication by KIT & IMEC**



#### **SEM** image of the device



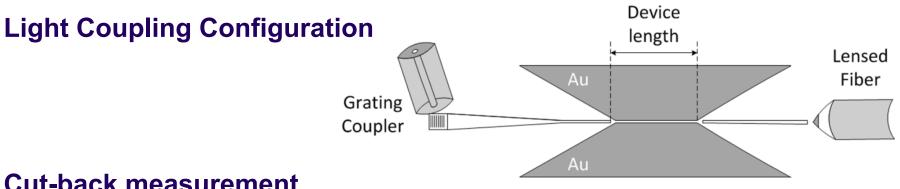




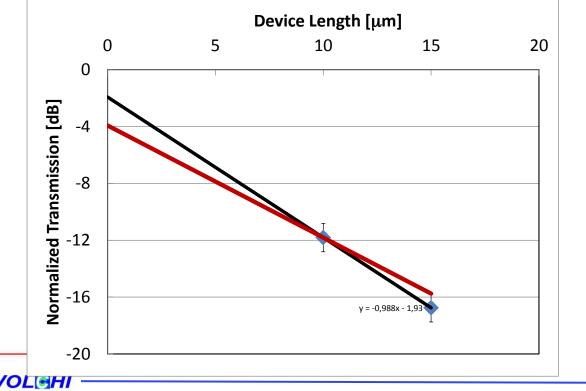
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# **Optical Characterization**





#### **Cut-back measurement**

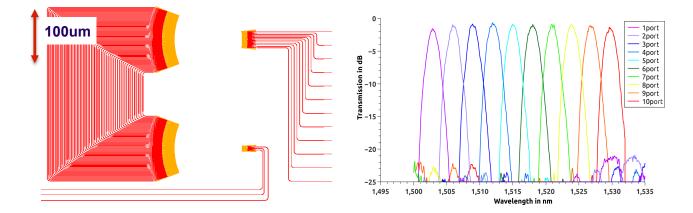


#### 2dB coupling loss per tapered coupler!

# **Optical filters**



Objective: 1<sup>st</sup> gen: 3nm bandwidth, 10dB suppression, 30nm FSR



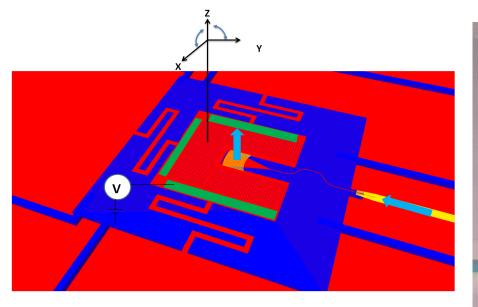
Device Details: 10x400 GHz AWG - size: 370x330 um2 - design FSR = 42 nm

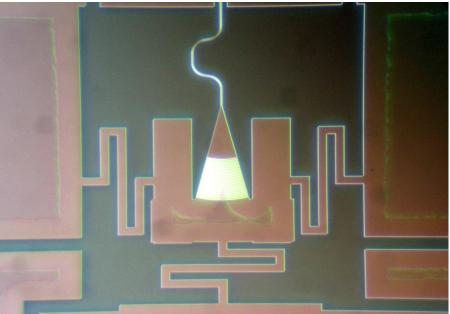
Measurement details: Insertion Loss: -.90dB non\_uniformity: 0.8 dB Crosstalk: 22 dB 1dB Bandwidth: 1.01 nm - 3dB Bandwidth: 1.75 nm - 10dB Bandwidth: 3.19 nm

## **Optical beam steerers**



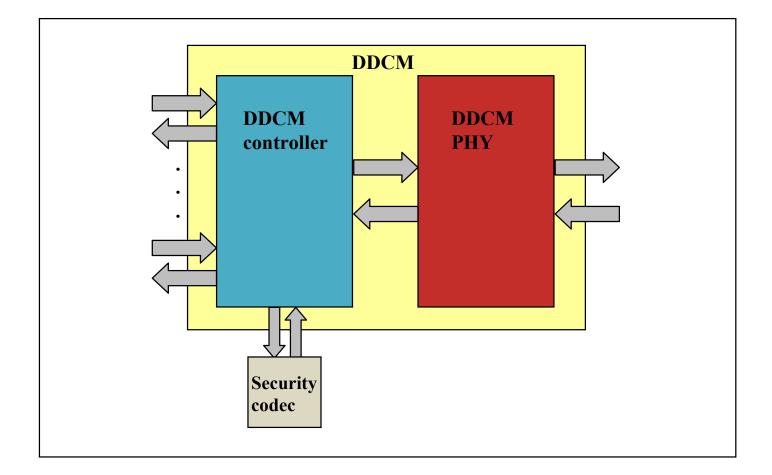
• Shifted focus to steerable gratings



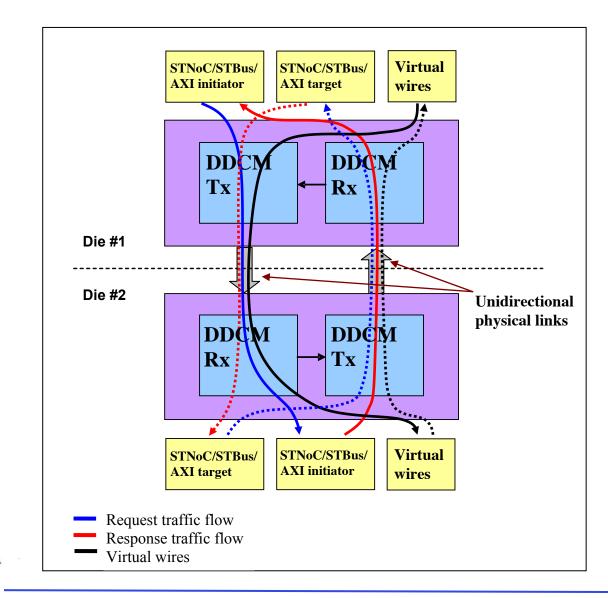






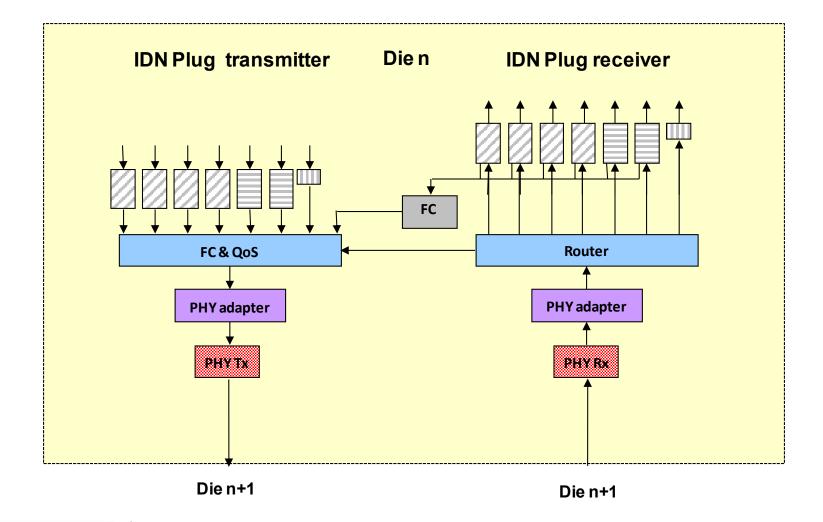






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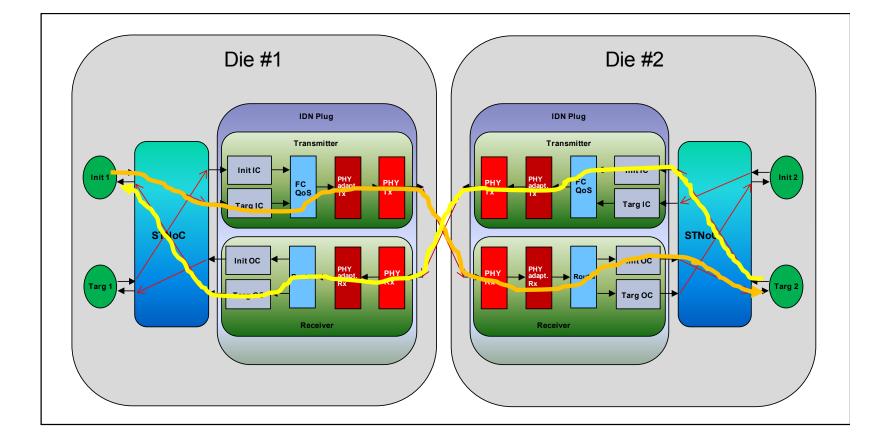




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#### **Resources**





## Outlook



#### KIT:

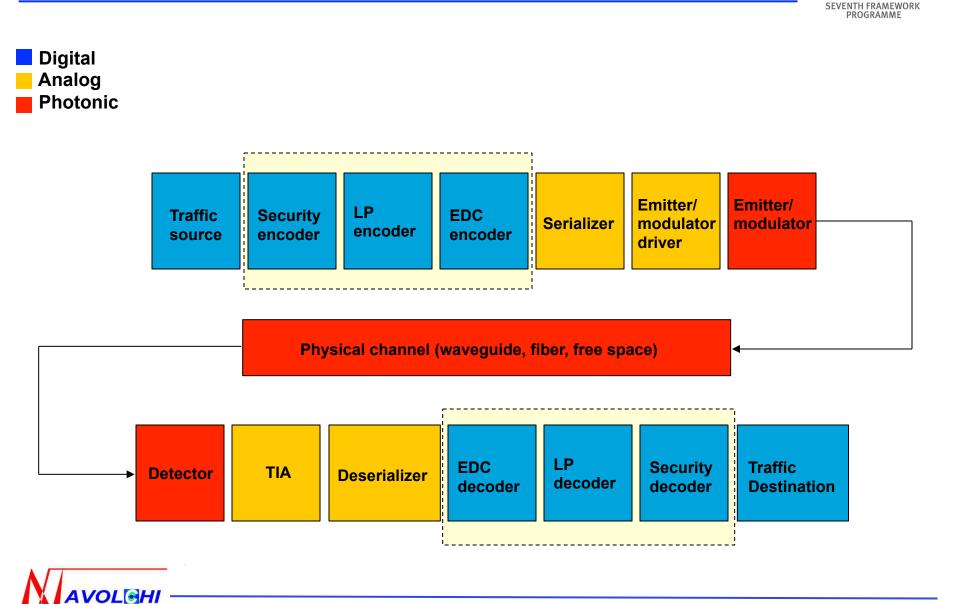
- 1. Further optimization of the process
- 2. Next post-processing is being carried out by KIT
- 3. New cut-back measurement

#### IMEC

- 1. Further optimize beam steerers
- 2. Waiting for input consortium on final design filters



### **Outlook ST**



# WP X Summary (Short Version for Coordinator Talk)



**Objectives:** 

**Achievements:** 

